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12/21/01

PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10032275	FILING DATE 12/21/2001	CLASS 205	SUBCLASS 640	GAU 1741	EXAMINER Parsons
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OK THP

****CONTINUING DATA VERIFIED:**

None THP

**** FOREIGN APPLICATIONS VERIFIED:**

None THP

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no		ATTORNEY DOCKET NO 005998
35 USC 119 conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no		
Verified and Acknowledged Examiners's Initials THP		

TITLE : Electrolyte composition and treatment for electrolytic chemical mechanical polishing

U.S. DEPT. OF COMM. / PAT. & TM-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for Q.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drawn	Fig. Drawn
		Print Fig.	
<input type="checkbox"/> TERMINAL		Primary Examiner	
DISCLAIMER		PREPARED FOR ISSUE	
		Application Examiner	
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